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TRANSMITTAL FORM

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Total Number of Pages in This Submission

Application Number 10/525,283

Filing Date 02/16/2005

First Named Inventor James S. Im

Art Unit

Examiner Name

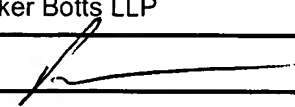
Attorney Docket Number A35185-PCT-USA (070050.2727)

ENCLOSURES (Check all that apply)

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| <input type="checkbox"/> Fee Transmittal Form | <input type="checkbox"/> Drawing(s) | <input type="checkbox"/> After Allowance Communication to TC |
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| <input type="checkbox"/> Amendment/Reply | <input type="checkbox"/> Petition | <input type="checkbox"/> Appeal Communication to TC (Appeal Notice, Brief, Reply Brief) |
| <input type="checkbox"/> After Final | <input type="checkbox"/> Petition to Convert to a Provisional Application | <input type="checkbox"/> Proprietary Information |
| <input type="checkbox"/> Affidavits/declaration(s) | <input type="checkbox"/> Power of Attorney, Revocation | <input type="checkbox"/> Status Letter |
| <input type="checkbox"/> Extension of Time Request | <input type="checkbox"/> Change of Correspondence Address | <input checked="" type="checkbox"/> Other Enclosure(s) (please identify below): |
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| <input type="checkbox"/> Certified Copy of Priority Document(s) | <input type="checkbox"/> CD, Number of CD(s) _____ | |
| <input type="checkbox"/> Reply to Missing Parts/Incomplete Application | <input type="checkbox"/> Landscape Table on CD | |
| <input type="checkbox"/> Reply to Missing Parts under 37 CFR 1.52 or 1.53 | | |

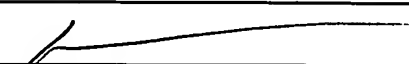
Remarks

SIGNATURE OF APPLICANT, ATTORNEY, OR AGENT

| | | | |
|--------------|---|--------------|--------|
| Firm Name | Baker Botts LLP | Customer No. | 21003 |
| Signature |  | | |
| Printed name | Paul A. Ragusa | | |
| Date | 10/07/2005 | Reg. No. | 38,587 |

CERTIFICATE OF TRANSMISSION/MAILING

I hereby certify that this correspondence is being facsimile transmitted to the USPTO or deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on the date shown below:

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| Signature |  | | |
| Typed or printed name | Paul A. Ragusa | Date | 10/07/2005 |

This collection of information is required by 37 CFR 1.5. The information is required to obtain or retain a benefit by the public which is to file (and by the USPTO to process) an application. Confidentiality is governed by 35 U.S.C. 122 and 37 CFR 1.11 and 1.14. This collection is estimated to 2 hours to complete, including gathering, preparing, and submitting the completed application form to the USPTO. Time will vary depending upon the individual case. Any comments on the amount of time you require to complete this form and/or suggestions for reducing this burden, should be sent to the Chief Information Officer, U.S. Patent and Trademark Office, U.S. Department of Commerce, P.O. Box 1450, Alexandria, VA 22313-1450. DO NOT SEND FEES OR COMPLETED FORMS TO THIS ADDRESS. SEND TO: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

11 OCT 2005

Applicants : Im et al. Customer No.: 21003
Serial No. : 10/525,283 Examiner : Not yet assigned
Filed : 02/16/2005 Group Art Unit: Not yet assigned
For : PROCESS AND SYSTEM FOR LASER CRYSTALLIZATION PROCESSING
OF FILM REGIONS ON A SUBSTRATE TO PROVIDE SUBSTANTIAL
UNIFORMITY WITHIN AREAS IN SUCH REGIONS AND EDGE AREAS
THEREOF, AND A STRUCTURE OF SUCH FILM REGIONS

INFORMATION DISCLOSURE STATEMENT

I hereby certify that this paper is being deposited with the
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October 7, 2005

Date of Deposit

Paul A. Ragusa

Attorney Name

38,587

Patent Reg. No.

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October 7, 2005

Date of Signature

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Pursuant to 37 C.F.R. §§ 1.56 and 1.97(b), applicants bring to the attention of the
Examiner the documents listed on the attached Form PTO 1449 and respectfully request that the
listed documents be considered by the Examiner and made of record in the above-captioned
application. Copies of all U.S. Patents and Applications are not enclosed pursuant to the wavier

of 37 CFR 1.98 (a)(2)(i) for all applications filed after June 30, 2003. However, copies of all of the other documents listed on the Form PTO-1449 are enclosed herewith.

This submission does not represent that a search has been made or that no better art exists and does not constitute an admission that the listed documents are material or constitute "prior art." If the Examiner applies the documents as prior art against any claim in the application and applicants determine that the cited documents do not constitute "prior art" under United States law, applicants reserve the right to present to the Office the relevant facts and law regarding the appropriate status of the documents.

Applicants further reserve the right to take appropriate action to establish the patentability of the disclosed invention over the listed documents, should the documents be applied against the claims of the present application.

This Information Disclosure Statement is being before the mailing of a First Office Action. Therefore, applicants believe no fee is due. If any additional fee is due, or if any overpayment has been made, the Commissioner is authorized to charge any such fee or credit any overpayment, to our Deposit Account No. 02-4377.

Respectfully submitted,

BAKER BOTTS L.L.P.

By: 

Paul A. Ragusa
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New York, NY 10012-4498
Attorney for Applicants
212-408-2500

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|---|---|--------------------------|
| Form PTO-1449 U.S. Department of Commerce (REV. 2-82) Patent and Trademark Office INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use several sheets if necessary) | Atty. Docket No. A35185-PCT-USA (070050.2727) | Serial No. 10/525,283 |
| | Applicant James S. Im | |
| | Filing Date 02/16/2005 | Group TBD |
| | Examiner Not yet assigned | |
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U.S. PATENT DOCUMENTS

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Examiner

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| Form PTO-1449 U.S. Department of Commerce (REV. 2-82) Patent and Trademark Office | Atty. Docket No. A35185-PCT-USA (070050.2727) | Serial No. 10/525,283 |
| INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use several sheets if necessary) | Applicant James S. Im | |
| | Filing Date 02/16/2005 | Group TBD |
| | Examiner Not yet assigned | |
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